#### DE LA RECHERCHE À L'INDUSTRIE





#### ELASTIC AND ACTIVATED THERMOELECTRIC TRANSPORT

#### AT THE BAND EDGES OF DISORDERED NANOWIRES

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References

- Riccardo Bosisio, PhD Thesis, Univ Paris 6 (sept 2014)
- **Riccardo Bosisio, Geneviève Fleury** and JLP, New Journal of Physics 16 (2014) 035004
- Riccardo Bosisio, Cosimo Gorini, Geneviève Fleury and JLP, New Journal of Physics 16 (2014) 095005
- Riccardo Bosisio, Cosimo Gorini, Geneviève Fleury and JLP, arXiv:1407.7020

Luchon, March 2015

www.cea.fr



Thermopower S (or Seebeck coeff.):

$$S = -\left(\frac{\Delta V}{\Delta T}\right)_{J^e=0}$$

Maximize the **efficiency** i.e. the **figure of merit** :

$$ZT = \frac{GS^2}{K^e + K^{ph}}T$$

... keeping a reasonable electrical output power (power factor) :

$$\mathcal{Q}=GS^2$$
 | page

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# Why semiconductor nanowires?

"... a newly emerging field of low-dimensional thermoelectricity, enabled by materials nanoscience and nanotechnology"

Dresselhaus et al: Adv. Mater. 2007

"... fundamental scientific challenges could be overcome by deeper understanding of charge and heat transport"

Majumdar: Science 2004



SC nanowires



#### Reduced thermal conductance

Phonon vs electrons mean free path, geometrical designs (Hochbaum 2008, Heron 2010)

#### Enhanced thermopower

Field effect transistors (*Brovman 2013, Roddaro 2013* & many others)

Scalable output power Arrays of parallel NWs (*Pregl 2013, Stranz 2013*)



#### Some experimental realizations



Karg et al. (IBM Zurich), 2013



Shin et al. (Seoul), 2011



Pregl et al. (TU Dresden), 2013





Fan et al. (Berkeley CA), 2008

Hochbaum et al. (Berkeley CA), 2008

Many experimental works and a few theoretical works





#### Nanowire in the Field Effect Transistor Device Configuration described with a 1D Anderson Model (tight binding 1d lattice with constant hopping and random site potentials)

- **1**. Thermopower of single NW: **low T elastic (tunnel)** regime
- 2. Thermopower of single NW: Intermediate T inelastic phonon-assisted regime (Mott variable range hopping)
- **3**. Large **Arrays of Parallel NWs**: Applications for
- Field control of the phonons at sub-micron scales (heat management)
- Energy harvesting (transforming the waste heat into useful electrical power)
- Hot spot cooling (important for microelectronics)



### Field-Effect Transistors (FET)



Setup used by P. Kim (Columbia) (2013)

"Seebeck" configuration: thermal bias "Peltier" configuration: voltage bias Single (or array of) doped nanowire(s) in the FET configuration

- **Substrate**: Electrically and thermally insulating
- Gate: «back» or «top»
- Heater: for thermoelectric measurements



 $\Pi = ST$ : equivalent within linear response if time-reversal symmetry preserved (Kelvin-Onsager relation)

Goal: Control of the thermopower with the back gate

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### **1D Anderson Model**

Prototypical model of localized system



- 1D electronic lattice with on-site (uniform) disorder V<sub>i</sub> ∈ (-W/2, W/2)
- Tight-binding Hamiltonian

$$\mathcal{H} = -t \sum_{i=1}^{N-1} \left( c_i^{\dagger} c_{i+1} + \text{h.c.} \right) + \sum_{i=1}^{N} (V_i + V_g) c_i^{\dagger} c_i$$

- All electrons are localized with localization length ξ (E)
- States distributed within an impurity band of width  $2E_B \approx 4t+W$
- Behavior of the typical thermopower when the gate voltage  $V_q$  is varied

# 1D density of states v and localization length $\xi$

 $V_G = 0$  Analytical expressions derived in the weak disorder limit



"Bulk" formulas:  

$$\nu_b(E) = \frac{1}{2\pi t \sqrt{1 - (E/2t)^2}}$$

$$\xi_b(E) = \frac{24}{W^2} \left(4t^2 - E^2\right)$$

$$\begin{aligned} & \text{"Edge" formulas:} \\ \nu_e(E) &= \sqrt{\frac{2}{\pi}} \left(\frac{12}{tW^2}\right)^{1/3} \frac{\mathcal{I}_1(X)}{[\mathcal{I}_{-1}(X)]^2} \\ & \xi_e(E) &= 2 \left(\frac{12t^2}{W^2}\right)^{1/3} \frac{\mathcal{I}_{-1}(X)}{\mathcal{I}_1(X)} \\ & \mathcal{I}_n(X) &= \int_0^\infty y^{n/2} e^{-\frac{1}{6}y^3 + 2Xy} \, dy \\ & X &= (|E| - 2t) t^{1/3} (12/W^2)^{2/3} \end{aligned}$$

B. Derrida & E. Gardner, *J. Physique* 45, 1283 (1984)

# 1. Elastic regime: Thermopower

<u>Theory</u>: Transport mechanism: elastic (coherent) tunnelling

Localized regime:  $\tau$  decays exponentially with length

 $[\ln \mathcal{T}]_0(E) = -\frac{2N}{\xi(E)}$ 

Typical  $\tau$  depends on the energy via  $\xi(E)$  (localization length)

Low Temperatures + Linear Response  $\rightarrow$  <u>Mott formula</u>:

$$S \approx \frac{\pi^2}{3} \frac{k_B}{e} k_B T \left. \frac{\mathrm{d} \ln \mathcal{T}}{\mathrm{d} E} \right|_{\mu}$$

Numerics:

Recursive Green Function calculation of S



#### Elastic Regime: Typical Thermopower



Large increase of the (typical) thermopower near the band edge, perfectly well described analytically

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R. Bosisio, G. Fleury, & J.-L. Pichard, New J. Phys. 16:035004 (2014)



#### **Elastic Regime: Fluctuations**



S. A. van Langen, P. G. Silvestrov, & C.W. J. Beenakker, Superlattices Microstruct. 23, 691 (1998).



### Elastic regime: Summary



Enhancement of the thermopower at the band edges (role of  $\xi(E)$ )



- Analytical description of the results
- Sommerfeld Expansion (low T) Wiedemann-Franz law  $\rightarrow$  Low S
- ~

...

Very low power factor  $Q = GS^2$ because of the exponential reduction of G at the band edges Typical thermopower Typical t

*Interest*: Ultra-low T : Peltier cooling?

 $OR \rightarrow$  toward higher temperatures!

#### 2: Intermediate Temperature Variable Range Hopping



#### **Transport Mechanisms** Low T: L << L\_M $\rightarrow$ elastic coherent transport Increasing T: $L_{M} \sim L \rightarrow$ onset of inelastic processes (VRH) $\longrightarrow T_{x} \simeq \frac{\xi}{2\nu L^{2}}$ Increasing T: $L_{M} \sim \xi \rightarrow$ simple activated transport (NNH) $\longrightarrow T_{M} \simeq \frac{2}{\xi\nu}$ $L_M \simeq \left(\frac{\xi}{2\nu T}\right)^{1/2}$ **Mott's Hopping Energy:** Relevant energy scale for $\frac{T}{\xi\nu} \gg k_B T$ $\Delta = k_B \sqrt{TT_M} \propto 1$ finite range of states activated transport contributing to transport 10 $2E_{B}/t$ NNH $k_B T_M / 1$ $k_B T/t$ Cut-off required by $k_B T_a/t$ $\Delta(T_M) = k_B T_M \le 2E_B$ **VRH** 0.01 $k_B T_x/t$ 0.001 **Elastic** 0.0001 0.5 1.5 2.5 1 2 $\overline{\epsilon}/t$ $|V_{q}-\mu|/t$ | PAGE 14 (T<sub>a</sub> : onset of simple activation in 1D (Kurkijärvi 1973, Raikh & Ruzin 1989))

# Inelastic (Phonon-Assisted) Regime: method

#### **Essential ingredients to build & solve the Random Resistor Network**

1. Transition rates (Fermi golden rule)



 $\Gamma_{i\alpha} = \gamma_{i\alpha} f_i \left[ 1 - f_\alpha(E_i) \right] \quad \alpha = L, R$  $\gamma_{i\alpha} \simeq \gamma_e \exp(-2x_{i\alpha}/\xi_i)$ 

Between localized states [Inelastic hopping rates]

$$\Gamma_{ij} = \gamma_{ij} f_i (1 - f_j) [N_{ij} + \theta(E_i - E_j)]$$
  
$$\gamma_{ij} \simeq \gamma_{ep} \exp(-2x_{ij}(\xi)) \longleftarrow \xi \text{ energy dependence}$$
  
usually neglected!

Between lead and localized states [Elastic tunneling rates]

$$\rightarrow \gamma_{ij} \propto |\langle \psi_i | \psi_j \rangle|^2 \simeq \gamma_{ep} \left| \frac{(1/\xi_j) \exp(-x_{ij}/\xi_i) - (1/\xi_i) \exp(-x_{ij}/\xi_j)}{(1/\xi_i - 1/\xi_j)} \right|^2$$

J-H. Jiang, O. Entin-Wohlman, and Y. Imry, Phys. Rev. B 87:205420 (2014)

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### Inelastic (Phonon-Assisted) Regime: method

2. Fermi distributions at equilibrium (no bias)

$$f_i^0 = \left(e^{(E_i - \mu)/kT} + 1\right)^{-1} \quad f_\alpha = f_\alpha^0(E_i) = \left(e^{(E_i - \mu)/kT} + 1\right)^{-1}$$

3. Occupation probabilities out of equilibrium

$$f_i = f_i^0 + \delta f_i \qquad f_\alpha = f_\alpha^0 + \delta f_\alpha$$

4. Currents  $I_{ij} = e (\Gamma_{ij} - \Gamma_{ji})$   $I_{i\alpha} = e (\Gamma_{i\alpha} - \Gamma_{\alpha i})$ 

5. Current conservation at every node i (Kirchoff) N coupled equations in N variables

$$\left(\sum_{j\neq i} I_{ij}\right) + I_{iL} + I_{iR} = 0 \qquad \Rightarrow \quad \delta f_i$$

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J-H. Jiang, O. Entin-Wohlman, and Y. Imry., Phys. Rev. B 87:205420 (2014)

### Miller – Abrahams Resistor Network

#### 6. Total particle/heat currents

Summing all terms flowing out from L(R) terminal

$$J_L^e = -\sum_i I_{iL} = \sum_i I_{iR},$$
  
$$J_{L(R)}^Q = \sum_i \left(\frac{E_i - \mu_{L(R)}}{e}\right) I_{L(R)i}.$$



(Having assumed Peltier configuration: T constant everywhere)

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J-H. Jiang, O. Entin-Wohlman, and Y. Imry., Phys. Rev. B 87:205420 (2014)

### Inelastic Regime: Typical thermopower



- Thermopower enhancement when the band edges are approached
- Rich behaviour of the T-dependence of the thermopower, "reflecting" the shape of the density of states and localization length

#### Inelastic regime: theory



#### Inelastic Regime: Typical thermopower



R. Bosisio, C. Gorini, G. Fleury, & J.-L. Pichard, New J. Phys. 16:095005 (2014)



#### Inelastic Regime: Mott energy

$$S = \frac{\langle E - \mu \rangle}{e T} = \frac{1}{e T} \frac{\int dE \left(E - \mu\right) \nu(E) p(E)}{\int dE \, \nu(E) \, p(E)}$$

**Mott's Hopping Energy:** 

Integration inside  $[\mu - \Delta, \mu + \Delta]$ 



S depends on the asymmetry of the states around  $\mu$  within  $[\mu - \Delta, \mu + \Delta]$ 

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- Neglect *inter*-wire hopping  $\rightarrow$  independent nanowires
- Transport through each NW: VRH / NNH regime (same treatment as before)

# Parallel nanowires: power factor and figure of merit





Parameters:  $M = 150, W = t, \gamma_e = \gamma_{ep} = t, L = 450$  P~µW for 10<sup>5</sup> NWs (1 cm) and  $\delta$ T-10 K | PAGE 23

R. Bosisio, C. Gorini, G. Fleury, & J.-L. Pichard, submitted to Phys. Rev. Appl. (2014)

# Parallel nanowires: power factor and figure of merit

Estimation of the parasitic phononic contribution to ZT



(For doped Si-NWs and SiO<sub>2</sub> substrate)

### Parallel nanowires: Hot Spot cooling

Hopping heat current through each localized state *i* 

$$I_i^Q = \sum_j I_{ij}^Q = \sum_j (E_j - E_i) I_{ij}^N$$
  
randomly distributed  $\rightarrow$  Local fluctuations

$$\mathcal{I}^Q_{x,y} = \sum\nolimits_{i \in \Lambda_{ph} \times \Lambda_{ph}(x,y)} I^Q_i$$

 $E_i$ 

 $\Lambda_{ph}$ : inelastic phonon mean free path = thermalization length in the substrate



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### Parallel nanowires: Hot Spot cooling



R. Bosisio, C. Gorini, G. Fleury, & J.-L. Pichard, submitted to Phys. Rev. Appl. (2014)

### Parallel nanowires: Hot Spot cooling

#### **Opportunities for a gate control of heat in microstructures**

E.g.: hot spot cooling in microelectronics: transferring heat some microns away



Estimate of the cooling power density:

 $\sim 10 \text{ W/cm}^2$ 

at  $\delta\mu$ =1mV ~ 7.7 x 10<sup>-2</sup> t, T = 75K ~ 0.5t (linear regime)

#### Electrodes of 1 cm long connected via 2.10<sup>5</sup> NWs

Strips of 1cm x 0.25  $\mu m$ ; T=77 K;  $\delta V = 1$  V 0.15 W taken from the cold strip towards the hot strip located at 10  $\mu$ m away

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### Summary

- Thermopower enhancement in disordered SC nws: low T and VRH
  - Opportunities offered by scalable modules



• Field control of phonon emission/absorption: Hot spot cooling





### GMT group summer 2013

#### Cosimo Gorini and Geneviève Fleury





Riccardo Bosisio PhD Thesis

## **Thank You**